Neural Networks, Fuzzy Systems and Other Computational Intelligence Techniques for Advanced Process Control

Guest Editors:

Dr. Jie Zhang
School of Engineering, Newcastle University, Newcastle upon Tyne NE1 7RU, UK

Prof. Dr. Meihong Wang
Department of Chemical and Biological Engineering, University of Sheffield, Sheffield S1 3JD, S Yorkshire, UK

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Message from the Guest Editors

This Special Issue on "Neural Networks, Fuzzy Systems, and Other Computational Intelligence Techniques for Advanced Process Control" aims to curate novel advances in the development and application of computational inteligence to address longstanding challenges in process systems engineering. Topics include but are not limited to:

- Data-driven modelling of industrial processes using machine learning techniques such as neural networks;
- Intelligent process control using neural networks, fuzzy systems, and other computational intelligence techniques;
- Intelligent image analysis in process systems engineering;
- Inteligent process monitoring using computational intelligence techniques; and
- Process optimisation using computational intelligence techniques.

Special Issue

Editor-in-Chief

Prof. Dr. Giancarlo Cravotto
Department of Drug Science and
Technology, University of Turin,
Via P. Giuria 9, 10125 Turin, Italy

Message from the Editor-in-Chief

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